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OFFICIALPATENT  
Customer No. 22,852  
Attorney Docket No. 04329.2072-01

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Katsuki OHASHI et al.

Application No.: 09/870,702

Group Art Unit: 1756

Filed: June 1, 2001

Examiner: Mohamedulla, Saleha R.

For: METHOD FOR REPAIRING A  
PHOTOMASK, METHOD FOR  
INSPECTING A PHOTOMASK,  
METHOD FOR  
MANUFACTURING A  
PHOTOMASK, AND METHOD  
FOR MANUFACTURING A  
SEMICONDUCTOR DEVICE.Assistant Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA: 22313-1450

Sir:

AMENDMENT

In reply to the Office Action mailed June 4, 2003, please amend the  
above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims in this paper.

**Remarks** follow the amendment section of this paper.

**Attachments** to this amendment include references JP 2054101 and JP  
2526986 with English Language Abstracts.

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